Article ID: 1003 - 6326(2005) 05 - 1190 - 04

Electrochemical studies on La-Co alloy film in acetamide-urea-NaBr melt system ¹⁰

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Abstract: The kinetics of LarCo alloy film in acetamide urear NaBr molten salt electrolyte at 353 K was investigated. It is shown that the reduction of Co(II) to Co is irreversible reaction with the transfer coefficient of 0. 28 and the diffusion coefficient of 7.46×10^{-5} cm²/s. While La(III) cannot be reduced to La directly; but can be codeposited with cobalt. The content of La in the uncrystallized LarCo alloy film increases with increasing cathodic overpotential, molar ratio of La³⁺ to Co²⁺ and electrolysis time as well, and reaches the maximum of 66.32%.

Key words: Læ Co alloy film; acetamidæ ureæ NaBr molten salt electrolyte; electroreduction; inductive co-deposition; rare earth elements

CLC number: 0 641.4 Document code: A

1 INTRODUCTION

The magnetic rare earth elements bring significant changes to the magnetic material industry due to their excellent magnetic and magneto-optical properties^[1]. Since La and Co are rich elements in nature, in addition to their relatively cheap prices, it would be very prospective to prepare magnetic functional materials using La-Co alloy. Compared with traditional techniques of spray and vacuum spattering or sputtering, electrodeposition is an economical method to develop alloy film due to a simple procedure and low expense. Because of the active chemical property of RE and Co, it is difficult to deposit RE-Co alloy in aqueous solution and studies on electrodeposition of RE-Co alloy film in organic electrolytes have been reported^[2-5].

Owing to the lower melting point (up to 315.2 K) and the higher electric conductivity of molten salt electrolyte of acetamide urea alkali halide ^[6-8] in the certain mixture, the acetamide urea-NaBr melt was chosen as electrolyte for depositing La and Co from La(NO₃)₃ and CoCl₂. In Refs. [8 - 14], the deposition of RE-Co alloy film from urea NaBr and urea NaBr KBr molten salt electrolytes was reported. In this paper, by using cyclic voltammetry, the results related to the reduction behaviors of La(III) and Co(II) in acetamide urea NaBr molten salt electrolyte and the relationship between alloy composition and molar ratio of La(III) to Co(II), electrolysis time and electrode potential were discussed. At the same time, the deposited film surface morphology was studied.

2 EXPERIMENTAL

Water free La(NO₃)₃ and CoCl₂ were made from A. R. La(NO₃)₃ • 6H₂O (Shanghai Chemical Co. China) and CoCl₂ (Beijing Red Star Chemical Co. China) by vacuum dehydration. Dried urea (Beijing Chemical Co. China), Acetamide (56%, mass fraction, Beijing Chemical Co. China) and NaBr (7%, mass fraction, Xi an Chemical Co. China) were uniformly mixed and then put into a cell with three electrodes. All measurements were carried out under the protection of argon gas at 353 K. The reference electrode was Ag/acetamide urea NaBr, to which all potentials in this paper were referred. Counter electrode was a platinum plate with high purity of 99.9%. The working electrode was a platinum (99.9%, 0.015 cm²) and a copper wire (99.9%, 0.35 cm²). Respectively CV techniques were employed using an Potentiostat HDV-7C and a HD-1A low & ultraslow frequency response analyzer (Sanming Instrumental Co. Fujian, China), and handled by 3086 X-Y data recorder (Sichuan Fourth Instruments, China).

3 RESULTS AND DISCUSSION

3.1 Electrochemical behavior of La(III) in melt of acetamide urea NaBr

The experiment is carried out with the melt of acetamide urea NaBr as supporting electrolyte and scanning rate is varied in 20, 50, 100 and 200

Received date: 2004 - 10 - 18; **Accepted date:** 2005 - 04 - 04

mV/s. In order to investigate the electrochemical behavior of the melt of acetamide urea NaBr, a cyclic voltammetry is recorded in a wide potential region of -1.5^-0 V with a copper wire as working electrode (see Fig. 1(a)). And then La (NO₃)₃ (324.9 g/mol) is added in the cell and CV curves (Fig. 1(b)) are recorded. Compared with Fig. 1 (a), there is an anodic current in Fig. 1(b) at potential of -1.10 V but no evident peak. In the meantime, there is no deposition after electrolysis in the potential range of $-1.10^--1.40$ V, which indicates that La(II) cannot be reduced to La in the melt and this coincides with McManis's report^[7].

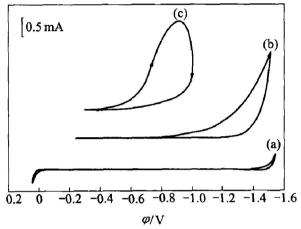


Fig. 1 Cyclic voltammograms of Cu electrode in different solutions
(a) —Melt of acetamide urea NaBr;
(b) —La(NO₃)₃-acetamide urea NaBr;
(c) —CoCl₂-acetamide urea NaBr
(Scanning rate 50 mV/s)

3. 2 Electrochemical behavior of Co(II) in melt of acetamide urea NaBr

When the previous experiment is repeated in the melt containing 0.06 mol/L CoCl₂, a peak appears in the negative scanning at -0.82 V (Fig. 1 (c)). This peak corresponds to the reduction of Co (II) and it is an irreversible reaction because of no oxidation peak in the backward scanning. After 20 min controlled potential electrolysis at -0.80 V, a gray color and uniform deposited film appears on the copper plate. Furthermore, the deposit is confirmed to be Co by EDS.

Fig. 2 shows a set of cyclic voltammograms recorded with increasing scanning rate in the region of Co(II) reduction. It is evident that the peak position shifts towards more negative potential values with the increase in scanning rate, indicating that the Co(II) reduction reaction is under diffusion control. In addition, as already discussed above, the Co(II) reduction reaction is shown to be highly irreversible, which can be seen from the linear relationship of peak potential (ϕ_p) and logarithm of scanning rate. By using relation for irreversible

electrochemical reaction at 353 K: $|\varphi_{p/2} - \varphi_p| = 1.857 \, RT / (\alpha nF)$, the average transfer coefficient can be calculated as $\alpha = 0.28 (n=2)$.

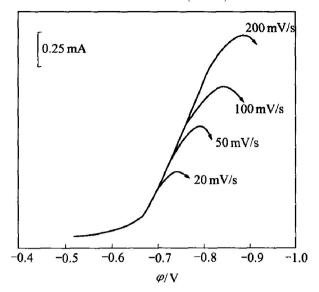


Fig. 2 Cyclic voltammograms of Pt electrode in CoCl₂-acetamide-urea-NaBr recorded at various scanning rates

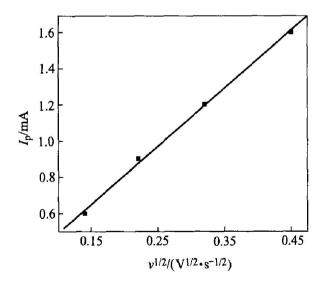


Fig. 3 Dependence of peak current on scanning rate

3. 3 Co-deposition of La (III) and Co(II) in melt of acetamide urea NaBr

3. 3. 1 Electrochemical behavior

Fig. 4 shows the cyclic voltammetry curve of $La(NO_3)_3(0.03 \text{ mol/L})-CoCl_2(0.06 \text{ mol/L})$ in the

melt of acetamide urea NaBr on Cu electrode. Compared with Fig. 1(c), the peak potential shifts toward more negative value, and the current increases evidently. It would be an inductive codeposition of Co and La. Under an electrolysis at cathodic potential of $-0.8\,\mathrm{V}$, a black deposit on Cu surface is got and it consists of La and Co according to EDS analysis, which further confirms that La(III) can be co-deposited with Co(II).

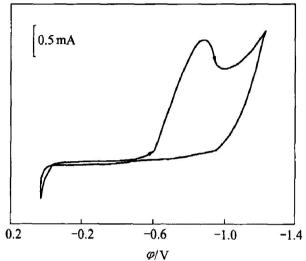


Fig. 4 Cyclic voltammogram of Cu electrode in La(NO₃)₃-CoCl₂-acetamide urea NaBr (Scanning rate 50 mV/s)

3. 3. 2 Effect of electrodeposition condition on alloy composition

3. 3. 2. 1 Effect of electrode potential

Table 1 shows the content of La-Co alloy film from 20 min controlled potential electrolysis at various potentials when keeping the molar ratio of La(III) to Co (II) at 1:1 in 0.06 mol/L La(NO₃)₃-0.06 mol/L CoCl₂-acetamide-urea-NaBr system. It can be seen that the content of La in alloy film increases with negative shift of cathodic potential and reaches the maximum value of 50.08% at -0.95 V. However, at more negative potential, the content of La decreases, which will be due to the polarization caused by concentration difference under these potentials. Scanning electron microscope (SEM) image of deposited film shows that the film is uniform and well-distributed

Table 1 Content of La in La-Co alloy film at various electrolysis potentials

Tilm at various electrolysis potentials				
Ψ V	w (La) / %	x (La) / %		
- 0.75	12. 31	5. 62		
- 0.85	33. 25	17.45		
- 0.95	50.08	29.85		
- 1.05	29. 09	14.83		
- 1.15	26. 85	13.47		

on the surface of Cu substrate.

3. 3. 2. 2 Effect of molar ratio of La(III) to Co(II)

After the completion of electrolysis at potential of -0.850 V for 20 min, the content of La in the deposited film increases with increasing molar ratio of La(III) to Co(II) (see Table 2). Fig. 5 shows the SEM image of deposited La Co alloy film.

Table 2 Content of La in Lar Co alloy film with different molar ratios of La(III) to Co(II)

x(La(II))/x(Co(II))	w (La) / %	x(La)/%
0.5: 1.0	9. 94	4. 47
1.0: 1.0	33. 25	17. 45
1.5: 1.0	39. 36	21. 6
2.0: 1.0	61.84	40. 74

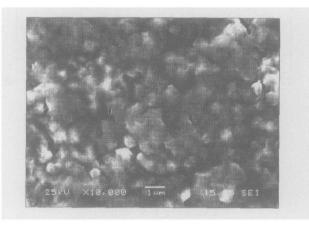


Fig. 5 SEM image of deposited film after heat treatment at 600 ℃

3. 3. 2. 3 Effect of time in controlled potential electrolysis

In order to investigate the relationship between the content of La in deposited alloy film and electrolysis time, the experiment is performed under molar ratio of La(III) to Co(II) of 2: 1 and cathodic potential of - 0.850 V (Table 3). The results show that the content of La increases at first and then decreases with time. The same trend is also observed from deposition of Gd-Co in melt of acetamide urea NaBr, which may be attributed to faster deposition speed of the iron triad elements compared with that of rare earth elements and the increasing extend of rare earth element content decreases with time.

3. 3. 2. 4 Effect of time in controlled current electrolysis

Table 4 shows that the content of La formed in the melt of La(NO_3) 3(0.12 mol/L)-CoCl₂(0.06 mol/L)-acetamide urea NaBr under cathodic current of 2.50 mA increases at first and then

decreases with time lasting. Moreover, the content of La deposited by controlled potential electrolysis is much higher than that by controlled current electrolysis at the same time.

Table 3 Content of La in La Co alloy film under controlled potential electrolysis

<i>t</i> / m in	w(La)/%	x (La) / %
10	33. 51	17.61
20	61. 84	40.74
30	6.32	45.51
40	61.11	40.00

Table 4 Content of La in LæCo alloy film under controlled current electrolysis

t/ min	w (La) / %	x (La) / %
10	8.81	3.93
20	16. 81	7. 89
30	17. 42	8. 22
40	12. 76	5. 84

3.4 Analysis of structural image of deposited film

A set of disordered peaks are found in X-ray diffusion pattern of La Co alloy film obtained from electrolysis in the system of La(NO₃)₃(0.12 mol/L)-CoCl₂ (0.06 mol/L)-acetamide urea NaBr, which suggests the deposited film is uncrystallized. However after 6 h heat treatment at 600 °C under argon gas protection, only diffraction peaks are observed in XRD pattern, which means that the alloy is crystallized during heat treatment. It can also be confirmed by the scanning electron microscope (SEM) image of La Co alloy film after heat-treatment at 600 °C (see Fig. 5).

4 CONCLUSIONS

- 1) Co(II) can be reduced to Co directly in the melt of acetamide urea NaBr and the reduction is an irreversible electrochemical reaction.
- 2) La(III) cannot be reduced to La in the melt of acetamide urea NaBr, but can be reduced inductively in the presence of Co.
- 3) The content of La in La-Co alloy film increases with increasing molar ratio of La(III) to Co (II), negative shift of cathodic potential and time lasting as well. The maximum value is 66.32%.
- 4) La-Co alloy film is uncrystallized when deposition from the melt of acetamide urea NaBr, but it becomes crystal after heat treatment.

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(Edited by YANG Bing)